Supporting Information

A two-terminal binary HfO₂ resistance switching random access memory for artificial synaptic device

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These file includes:

1. Figure S1 The fabrication processes of the HfO₂ RRAM device.

2. Figure S2 The Raman spectrum of the as-prepared HfO_2 sample.

3. Figure S3 The solutions mixed with HfO_2 powders purchased from Aladdin (Left) and prepared by hydrothermal method (Right).

4. Figure S4 The SEM image of the as prepared HfO₂ sample.

5. Figure S5 The SEM image of the HfO₂ purchased from Aladdin corporation.

6. Figure S6 The TEM image of the as prepared HfO_2 sample. M, O, and T represent monoclinic, orthorhombic, and tetragonal phases.

7. Figure S7 The TEM image of the as prepared HfO₂ sample, in which the lattice vacancies in different regions are clearly identified.

8. Figure S8 The SEM images and EDS spectra of the HfO_2 MIM device after the measurement.

9. Figure S9 The XPS spectra of the HfO₂ MIM device after the measurement.



Figure S1 The fabrication processes of the HfO₂ RRAM device.

 $(a \rightarrow b)$ The as-prepared HfO₂ powders were loaded into a stainless steel mould; $(b \rightarrow c \rightarrow d)$ The as-prepared HfO₂ powders were re-shaped into a wafer-liked HfO₂ sample under 8 MPa by using a powder tablet press; $(d \rightarrow e \rightarrow f)$ The bottom and top Cu electrodes were deposited onto the re-shaped wafer-liked HfO₂ sample by using a thermal evaporation method.



Figure S2 The Raman spectrum of the as-prepared HfO₂ sample.



Figure S3 The solutions mixed with HfO₂ powders purchased from Aladdin (Left) and prepared by hydrothermal method (Right).



Figure S4 The SEM image of the as prepared HfO₂ sample.



Figure S5 The SEM image of the HfO_2 purchased from Aladdin corporation.



Figure S6 The TEM image of the as prepared HfO_2 sample. M, O, and T represent monoclinic, orthorhombic, and tetragonal phases.



Figure S7 The TEM image of the as prepared HfO₂ sample, in which the lattice vacancies in different regions are clearly identified.



Figure S8 The SEM images and EDS spectra of the HfO₂ MIM device after the measurement.



Figure S9 The XPS spectra of the HfO₂ MIM device after the measurement.